

<b>Notice of References Cited</b>	Application/Control No. 10/085,425		Applicant(s)/Patent Under Reexamination FESQ ET AL.	
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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	J	US-			
	K	US-			
	L	US-			
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